

Semi-transparent a-SiC:H solar cells for self-powered photovoltaic–electrochromic devices

John N. Bullock^{*}, Clemens Bechinger, David K. Benson, Howard M. Branz

National Renewable Energy Laboratory, Golden, CO 80401, USA

Abstract

Self-powered 'smart' windows for active control of building heating and cooling represent a potential new market for amorphous-silicon based photovoltaics. Retrofit applications to existing windows are facilitated by the tandem photovoltaic–electrochromic (PV-EC) device, in which a wide-gap amorphous silicon-based alloy (a-SiC:H) photovoltaic cell is deposited together with an EC optical transmittance modulator in a monolithic coating on a single substrate. In this paper, studies of transparent wide-gap a-SiC:H thin-films and p–i–n cells designed for use in the PV-EC device are described. Using optimized a-SiC:H i-layer material, J_{sc} of 3.9 mA/cm² and V_{oc} of 0.92 V is achieved, adequate to color our low-voltage Li-based EC devices in less than one minute, and good progress toward the required transparency is shown.

1. Introduction

Self-powered, smart windows are a potential new a-Si:H based photovoltaic (PV) application. A variable transmittance window coating, operated as part of an intelligent building energy management system, can provide substantial total energy savings [1–3]. These windows utilize an electro-optic modulator based on electrochromic (EC) thin films that exhibit well-controlled and reversible changes in optical absorption under low applied voltages.

Current proposals call for a connection to an external power source, either a battery at each window or low-voltage wiring throughout the building. However, simulations show that a building energy management system can be highly effective when constructed from independent, smart components [4]. This system replaces centralized intelligent control

with distributed smart components, each reacting to local occupant and energy management requirements. The monolithic, tandem PV-EC device [5], being self-powered, can be an important component in such a system [4]. In this paper, we describe progress toward a tandem PV-EC device composed of a wide-gap amorphous SiC alloy (a-SiC:H) PV cell and an all solid-state EC device based on Li-doped WO₃.

Since its discovery in 1969, electrochromism in transition metal oxides has been studied [6]. Still, the fundamental mechanism of the change in optical properties remains controversial [7–10]. For device engineering, however, a simple phenomenological model suffices. The features of an EC material (e.g. WO₃) that are important for EC device operation are that (1) a reversible insertion-phase compound is formed with small, mobile ions (e.g. Li⁺) and (2) each ion inserted induces an optical absorption center [11,12]. Thus, by inserting and extracting Li⁺, the optical absorption of a WO₃ film can be continu-

^{*} Correspondence author. Tel: +1-303 384 6698; fax: +1-303 384 6531; e-mail: jbullock@nrel.gov.

SnO ₂ (A)
ion storage material (V ₂ O ₅)
ion conductor (MgF ₂)
electrochromic material (WO ₃)
SnO ₂ (B)
n-type μ c-SiC:H
intrinsic a-SiC:H
p-type a-SiC:H
SnO ₂ (C)
substrate

Fig. 1. Schematic structure of the proposed monolithic photo-voltaic-electrochromic device.

ously and reversibly varied. Transport of Li⁺ in and out of a WO₃ film is balanced by an equal but opposite electron current as given by the reversible reaction



which converts transparent WO₃ into optically absorbing Li_xWO₃ and back again. The concentration of Li⁺, x , determines the absorption coefficient of the Li_xWO₃ film and thus the transparency of the EC device. The internal chemical potential of Li⁺ in the WO₃ film is also determined by x , while the total external Li⁺ chemical potential is the sum of the internal chemical potential and any applied electrostatic potential [13].

The upper half of Fig. 1 shows our EC device structure. The EC layer (WO₃) is joined by MgF₂ to an ion storage layer (V₂O₅), which accommodates Li⁺ but does not change color. The MgF₂ layer

conducts Li⁺ ions but is otherwise electrically insulating. A voltage bias applied to the SnO₂ contact layers shifts the Li⁺ chemical potential balance between the WO₃ and V₂O₅ layers, causing Li⁺ flow and a change in the coloration state of the device [13]. In the tandem PV-EC device, this potential is supplied by the PV cell integrated with the EC device, as shown in Fig. 1.

The PV cell in the PV-EC tandem device must have the following features: (1) sufficient transparency in the visible to allow an acceptable total window transmittance in the bleached state; (2) an open-circuit voltage (V_{oc}) large enough to shift the Li⁺ chemical potential balance in the EC device into the opaque state; and (3) a short-circuit current (J_{sc}) adequate to achieve EC coloration in a reasonable time (minutes). For the new, low-voltage EC devices we are developing [14], this means $V_{oc} > 1$ V and $J_{sc} > 0.1$ mA/cm². For good visible transparency and color fidelity, we estimate that a cell transmittance of 70% at photon energies below 2.4 eV will be required.

2. Experimental procedures

We prepared intrinsic a-SiC:H samples and p-i-n cells in a single-chamber radio-frequency (rf) diode glow-discharge reactor. The intrinsic samples were deposited from SiH₄ and CH₄ with varying H₂ dilutions. The hydrogen dilution ratio (H₂ flow to

Table 1
Intrinsic a-SiC:H deposition conditions, carbon content, and selected electronic and optical properties

ID #	SiH ₄ (sccm)	CH ₄ (sccm)	H ₂ (sccm)	Power (W)	Pressure (Torr)	E_{st} (eV)	σ_{ph} (nS/cm)	σ_{ph}/σ_d ($\times 10^4$)
1	45	0	0	0.4	0.6	2.16	12000	19
2	40	10	0	0.4	0.6	2.25	8200	130
3	20	20	0	0.8	0.7	2.36	420	2.8
4	10	40	0	0.4	0.6	2.58	1.7	> 4.6
5	5	10	75	0.8	2.5	2.40	77	18
6	3	12	75	0.8	3.0	2.43	61	4.8
7	0.75	3	75	0.8	3.0	2.14	960	35
8	0.75	3	75	1.6	3.0	2.21	740	25
9	1.5	20	86	0.8	3.0	2.59	1.6	> 3.8
10	0.75	10	89	0.8	3.0	2.38	4.3	> 2.1
11	0.75	10	89	0.8	3.0	2.41	4.5	> 1.5

SiH₄ plus CH₄ flow) ranged from 0 to 20, and the CH₄ to SiH₄ ratio from 0 to 14. The substrate temperature was varied from 160 to 300°C. The rf power was varied from 0.4 to 1.6 W. Table 1 shows the deposition conditions used. Samples were deposited simultaneously on Corning 7059 glass and crystalline silicon substrates.

We determined sample thickness and growth rate by step profilometry. We define the 'semi-transparency' gap, E_{st} , as the photon energy where the absorption coefficient is $5 \times 10^4 \text{ cm}^{-1}$. (At this energy, approximately half the photons are transmitted through a 1000 Å film.) We calculated the semi-transparency gap, E_{st} , from optical transmission spectra. We measured the dark conductivity (σ_d) and the 1-sun photoconductivity (σ_{ph}) at room temperature with parallel, coplanar Cr contacts.

In the p-i-n cells, boron-doped a-SiC:H was prepared from 0.6 Torr total pressure of SiH₄, CH₄, and 3% trimethylboron (TMB) in He, at flow rates of 25, 50 and 7 sccm, respectively. The substrate temperature was 250°C and the rf power was 0.4 W. This material is the a-SiC:H p-layer typically used as a window-layer in our standard a-Si:H solar cells and has $E_{st} \approx 2.4 \text{ eV}$ and a room-temperature conductivity of $1.2 \times 10^{-6} \text{ S/cm}$. The n-layer was a microcrystalline silicon layer also adopted from our standard a-Si:H cells. Its deposition parameters were SiH₄ and 3% PH₃ in He at 0.9 and 0.8 sccm, respectively, with 90 sccm H₂ dilution, at 3.0 Torr, 200°C, and 1.5 W. This material has a room-temperature conductivity of 63 S/cm. The i-layer material (#5 in Table 1) was selected from the set of a-SiC:H depositions as described below.

We fabricated thin film PV cells on textured SnO₂ tin oxide coated Corning 7059 glass. The cell structure was glass/SnO₂/100 Å p-layer/1500 Å i-layer/250 Å μ c-n-layer/Pd. We measured the current-voltage (J - V) characteristics of the cells under 1-sun illumination through the glass substrate. The transparency of the cell, without a Pd back contact, was evaluated by transmission spectroscopy.

We tested the electrical compatibility of the PV and EC devices by placing them side-by-side under 1-sun illumination with external electrical connections. This configuration simulates the monolithic device shown in Fig. 1, but with external electrical connections. The changes in the white light transmis-

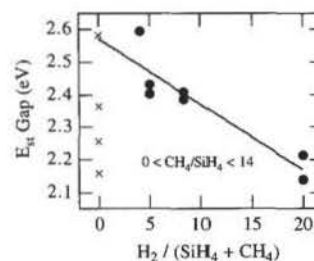


Fig. 2. Semi-transparency gap, E_{st} , as a function of H₂ dilution ratio. Crosses indicate samples with no H₂ dilution and various CH₄:SiH₄ ratios. Filled points indicate those with non-zero H₂ dilution.

sion of the EC device were monitored with a short-circuited Si photodiode behind the EC device. We measured the voltage and current supplied by the PV cell and simultaneously the transmittance of the EC device as a function of time after the two devices were connected.

3. Results

Table 1 shows the results of the optical and electrical measurements on the set of intrinsic films. Fig. 2 shows the semi-transparency gap as a function of the hydrogen dilution ratio. Fig. 3 shows the transmission spectrum and 1-sun J - V curve for the cell fabricated with an i-layer of the target material (# 5). The cell has a J_{sc} of 3.9 mA/cm², a fill-factor of 0.58, and an V_{oc} of 0.92 V. Its transparency is

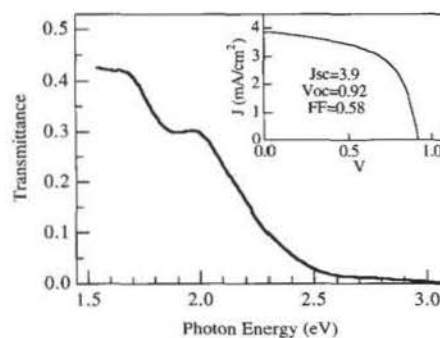


Fig. 3. Optical transmission spectrum and 1-sun J - V characteristic of the transparent PV cell using the target a-SiC:H i-layer material.

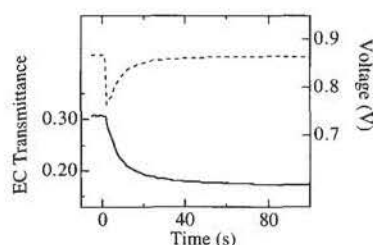


Fig. 4. White light transmission through an EC device and the switching voltage supplied by the a-SiC:H PV cell under 1-sun illumination as a function of time as the EC device is colored. The EC transmission is cut by about 50% by the use of a thin Au top contact instead of transparent SnO₂.

between 30% and 40% at long wavelengths (below 2.0 eV). With white-light back illumination, it appears pale yellow–orange.

Fig. 4 shows the voltage and transmission transients for the side-by-side bench test of PV and EC integration. The EC device is described elsewhere [14]. When the electrical connection is completed, the EC device transmission drops within one minute to about half its bleached-state transmittance, while the voltage required to achieve this coloration remains below 0.87 V. The coloration current is related to the PV voltage by its J – V characteristic as shown in Fig. 3.

4. Discussion

For films without hydrogen dilution, the semi-transparency gap increases from 2.16 to 2.58 eV and the photo-to-dark conductivity ratio drops from 1.3×10^6 to 2.8×10^4 as the methane fraction increases. For samples grown with hydrogen dilution, E_{st} is well correlated to the hydrogen dilution ratio, with a weak dependence on the methane-to-silane ratio. In this regime, samples with widely varying methane-to-silane gas-flow ratios, but the same hydrogen dilution, produce comparable optical gaps.

Several samples had semi-transparency gaps near our target of 2.4 eV: Samples 3, 5, 6, 10 and 11. As these samples were deposited with widely varying deposition conditions, the photoconductivities of these samples ranged from 4.3×10^{-9} to 4.2×10^{-7} S/cm and the photo-to-dark conductivity ratios varied from at least 1.5×10^4 to 1.8×10^5 . Because of

its semi-transparency gap of 2.40 eV and good photo-to-dark conductivity ratio of 1.8×10^5 , we chose sample 5 as the candidate i-layer material for the transparent PV cell.

The cell transparency is good below 2.0 eV, although still less than our target of 70%. There are undoubtedly many contributions to the excessive absorption of the PV cell. An important source of this absorption is our use of textured SnO₂ substrates, which causes significant undesirable light trapping. Above 2.0 eV the absorption is also much larger than desired. The i-layer material is semi-transparent at 2.4 eV, but is too thick. Another possible source of the significant cell absorption between 2.0 and 2.4 eV is the un-optimized p- and n-layers.

5. Conclusions

We have fabricated semi-transparent PV cells for use in monolithic PV-EC devices. The long wavelength transparency of our best cell remains below our design target. Transparency will be improved by incorporating thinner cell layers and more transparent, lower haze SnO₂. In addition, the large blue absorption in the cell, not found in the i-layer material, suggests that improvements in the doped layer transparencies are needed.

The V_{oc} of this cell is close to our 1.0 V target. The J_{sc} , however, is at least one order of magnitude larger than our target. Given the excessive absorption in the cell, we will try to trade off the excess current for increased transparency in future cells.

A side-by-side bench test of the electrical compatibility of our PV and EC devices showed that we can achieve good coloration with good switching speed with voltages well below 1 V. Thus we fully expect that a monolithic PV-EC device will function similarly.

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